

**Statistical and Local Structure of Dy³⁺-doped Bi₄Ge₃O₁₂ Crystals: a Role of Activator
Concentration in Structural Effects**

Galina M. Kuz'micheva^a, Liudmila I. Ivleva^b, Irina A. Kaurova^{a,*}, Evgeny V. Khramov^c,
Elizaveta E. Dunaeva^b, Roman D. Svetogorov^c, and Victor B. Rybakov^d

^a*MIREA - Russian Technological University, 78 Vernadskogo pr., Moscow 119454, Russia*

^b*Prokhorov General Physics Institute, Russian Academy of Sciences, 38 Vavilova str., Moscow
119991, Russia*

^c*National Research Center «Kurchatov Institute», 1 Akademika Kurchatova pl., Moscow
123182, Russia*

^d*Lomonosov State University, 1-3 Vorobyovy Gory, Moscow 119992, Russia*

Supporting Information

Table S1. Coordinates of atoms, anisotropic displacement parameters $U_{\text{eq}} \times 10^2$ (\AA^2), site occupancies p (SOF), main interatomic distances d (\AA) and bond angles (ω , deg) in the structures of BGO:Dy crystals according to the XRD data

Parameter	$\text{Bi}_4\text{Ge}_3\text{O}_{12}:1.0\text{wt.\%Dy}_2\text{O}_3$ (BGO:1.0%Dy)^a	$\text{Bi}_4\text{Ge}_3\text{O}_{12}:0.1\text{wt.\%Dy}_2\text{O}_3$ (BGO:0.1%Dy)^b
Bi/Dy (16c)		
x	0.08739(4)	0.91253(8)
p (Bi)	0.3293(40)	0.3330(9)
p (Dy)	0.0040(4)	0.0003(9)
U_{eq}	2.05(2)	2.28(6)
Ge (12a)		
x	0	0
y	1/4	3/4
z	3/8	5/8
p	0.2500	0.2500
U_{eq}	1.86(5)	2.1(1)
O (48e)		
x	0.0721(11)	0.925(3)
y	0.1260(10)	0.874(2)
z	0.2905(9)	0.710(2)
p	1.0	1.0
U_{eq}	2.6(2)	3.1(4)
Bi – 3 × O1 – 3 × O2 [Bi–O] _{avr}	2.177(10) 2.587(10) 2.382	2.17(2) 2.59(2) 2.38
Ge – 4 × O	1.748(10)	1.76(2)
O2–Ge–O2	104.9(3)	104.7(6)
O2–Ge–O2	119.0(6)	119.5(9)
O1–Bi–O2	84.5(4)	84.5(3)
O1–Bi–O2	70.8(4)	70.9(8)
O1–Bi–O1	84.52(15)	83.4(9)
O2–Bi–O2	153.7(4)	152.7(9)

^a right form, ^b left form

Table S2. Coordinates of atoms, isotropic displacement parameters U_{iso} (\AA^2), site occupancies p (SOF) and main interatomic distances d (\AA) in the structures of powdered BGO:Dy crystals according to the Rietveld refinement

Parameter	$\text{Bi}_4\text{Ge}_3\text{O}_{12}:1.0\text{wt.\%Dy}_2\text{O}_3$ (BGO:1.0%Dy)	$\text{Bi}_4\text{Ge}_3\text{O}_{12}:0.1\text{wt.\%Dy}_2\text{O}_3$ (BGO:0.1%Dy)
a , \AA	10.52689(9)	10.52421(4)
Scherrer size, nm	680	1330
Bi/Dy		
$x\ y\ z$	0.08732(4)	0.08737(6)
U_{iso}	0.01604(12)	0.0269(2)
p (Bi)	0.993(1)	0.998(1)
p (Dy)	0.007(1)	0.002(1)
Ge		
$x\ y\ z$	0 0 0	0 0 0
U_{iso}	0.0184(6)	0.0236(12)
p	1.0	1.0
O		
$x\ y\ z$	0.0714(4) 0.1261(4) 0.2897(4)	0.0699(6) 0.1297(7) 0.2868(6)
U_{iso}	0.0221(15)	0.030(4)
p	1.0	1.0
$R_p/R_{wp}/GOF$	0.75/1.35/1.19	1.36/2.44/1.89
Bi – 3 × O1	2.169(4)	2.148(3)
– 3 × O2	2.591(5)	2.640(5)
[Bi–O] _{avr}	2.380	2.394
Ge – 4 × O	1.748(4)	1.729(4)

Table S3. The results of two-sphere EXAFS fit for BGO:Dy crystals (Bi L₃-edge; k -range: 2 – 13 \AA^{-1} ; R , interatomic distance (the length for single scattering path); CN, coordination number; σ^2 , the Debye–Waller factor). Coordination numbers were defined to be equal during the fit.

Sample	$R_{\text{Bi-O}}$, \AA	CN Bi	σ^2 , \AA^2	R_f , %
$\text{Bi}_4\text{Ge}_3\text{O}_{12}:1.0\text{wt.\%Dy}$ (BGO:1.0%Dy)	2.13 ± 0.012	2.9 ± 0.4	0.0038 ± 0.001	0.9
	2.57 ± 0.016	2.9 ± 0.4	0.0057 ± 0.002	
$\text{Bi}_4\text{Ge}_3\text{O}_{12}:0.1\text{wt.\%Dy}$ (BGO:0.1%Dy)	2.13 ± 0.001	2.5 ± 0.3	0.0020 ± 0.001	1.0
	2.58 ± 0.015	2.5 ± 0.3	0.0045 ± 0.002	

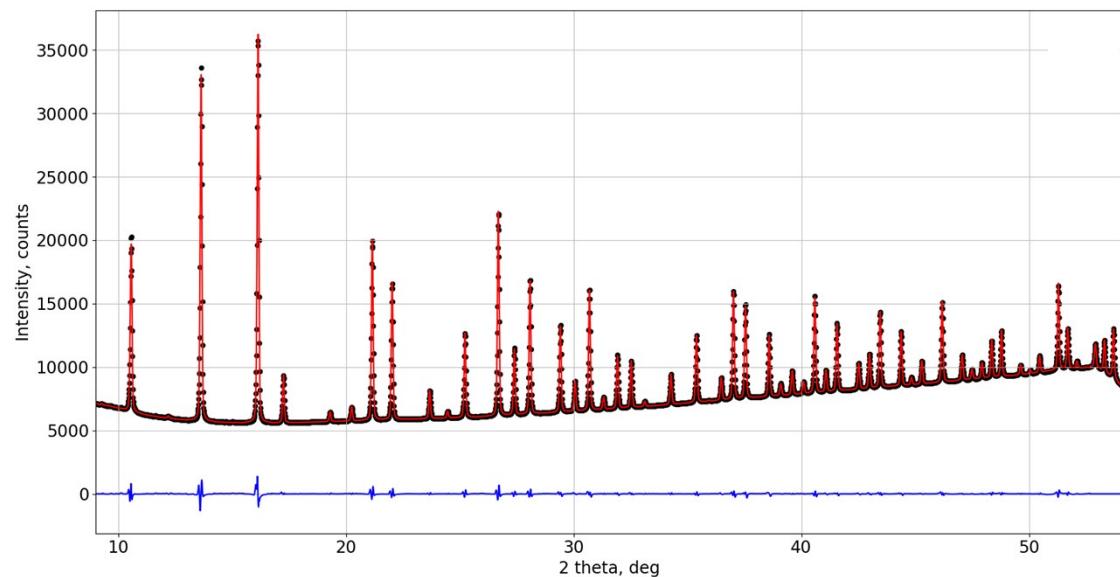


Figure S1. Observed (black dots), calculated (red line), and difference (blue line) X-ray powder patterns for BGO:1.0%Dy sample.

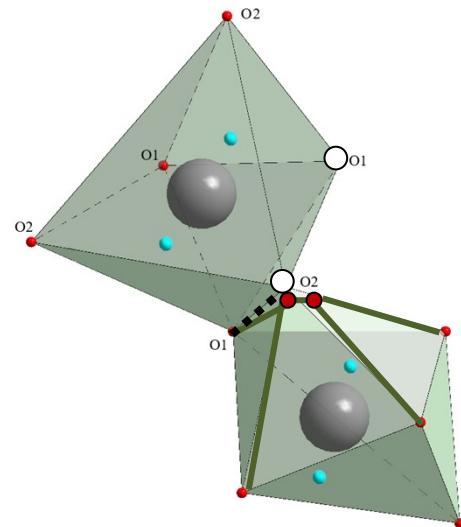


Figure S2. An idealized model of rearrangement of the BiO₆ octahedron into a vacancy octahedron (BiO₅) and DyO₆ octahedron into a DyO₇ octahedron with a split vertex.

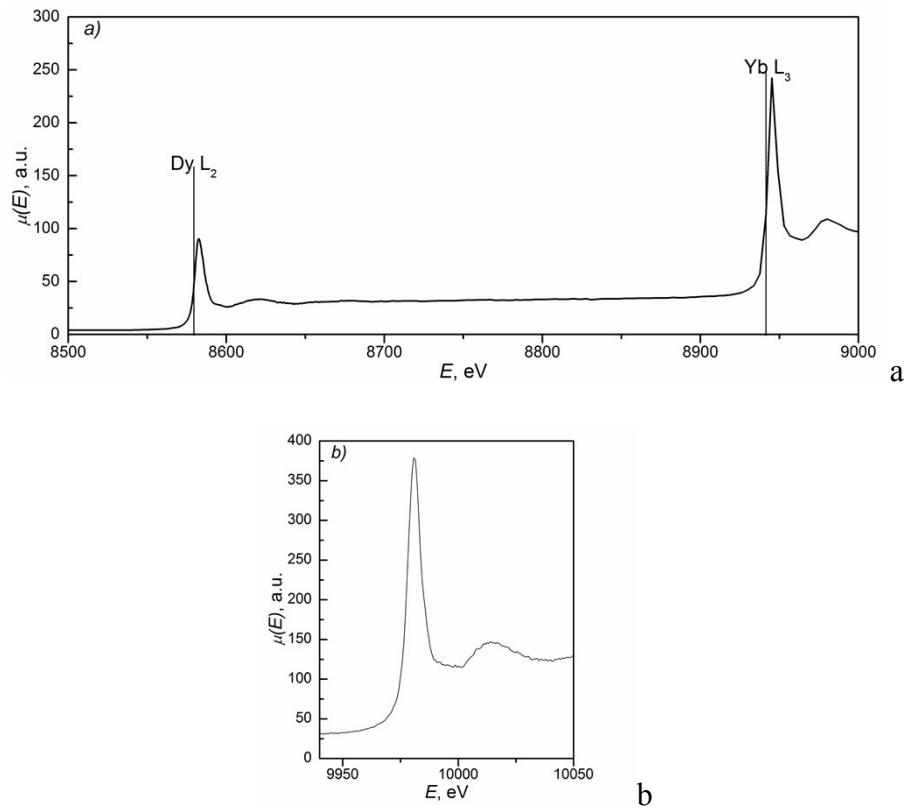


Figure S3. The Dy L₂ and Yb L₃ edge steps (a) and the Yb L₂ edge step (b) for the BGO:1.0%Dy sample. The fluorescence is normalized to the intensity of the incident beam.

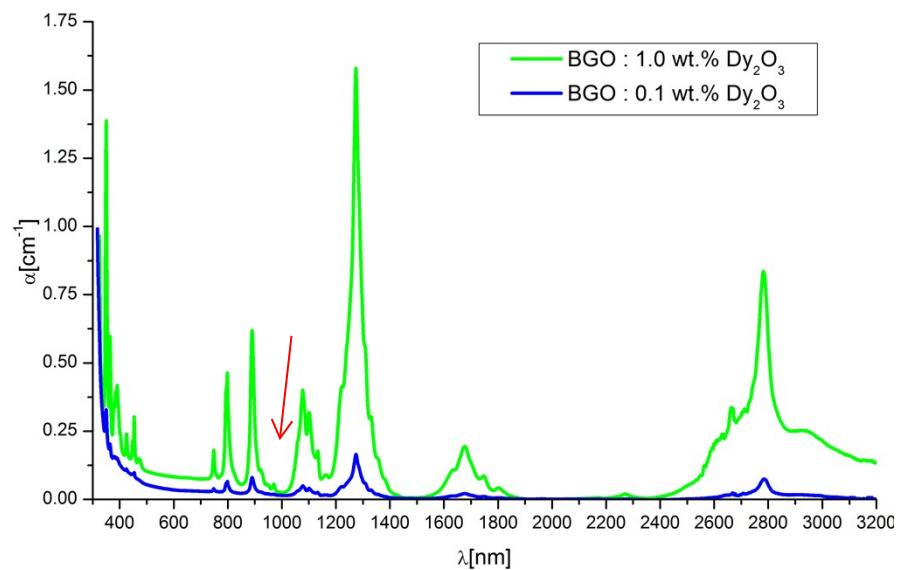


Figure S4. Absorption spectra for the BGO:1.0%Dy and BGO:0.1%Dy samples.

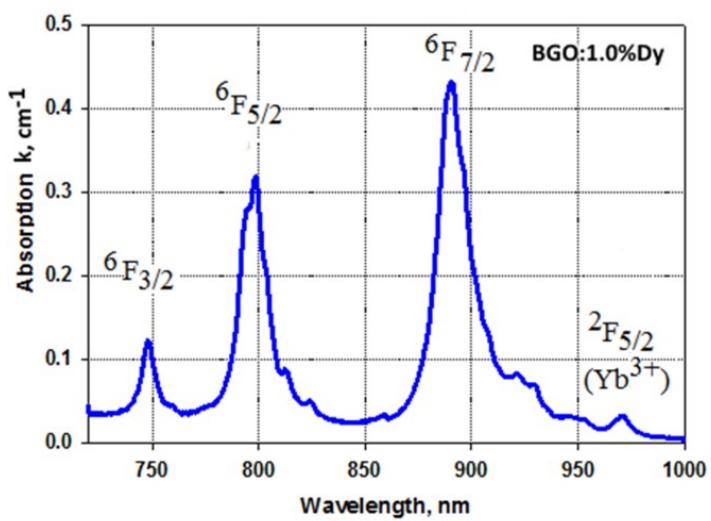


Figure S5. A part of the absorption spectra of the BGO:1.0%Dy.

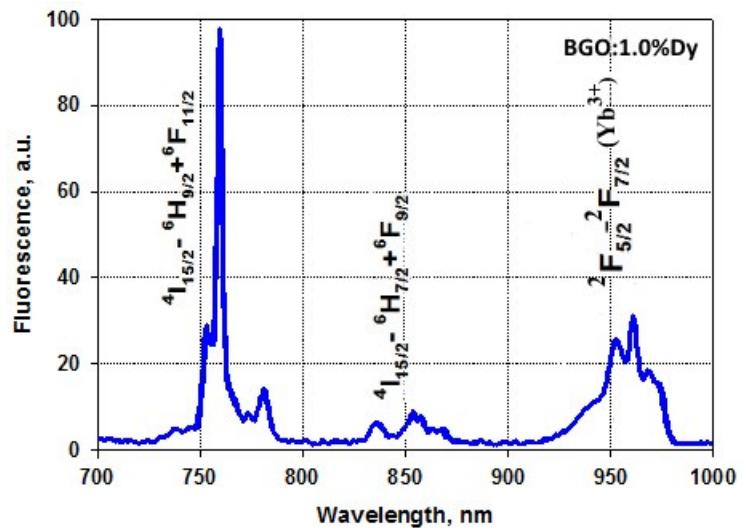


Figure S6. Luminescence spectrum for the BGO:1.0%Dy crystal under excitation by diode laser at 453 nm.